

**Search Notes**

Application No.

09/892,023

Examiner

W. David Coleman

Applicant(s)

TAKAGI ET AL.

Art Unit

2823

**SEARCHED**

Class	Subclass	Date	Examiner
438	706 730	12/8/2004	WDC

**INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner
438	706	12/8/2004	WDC

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
EAST 1.4.1; Applicants claim a dry etch recipe wherein chlorine is used as the starting composition and CHF <sub>3</sub> is added later to		
etch the lower most layer.	12/8/2004	WDC